NOTES:

1. SUBSTRATE: FUSED SILICA

2. SURFACE S2 TO BE PARALLEL TO SURFACE S1 TO WITHIN <5 ARCMIN

3. COATING (APPLY ACROSS COATING APERTURE) \$1: R(AVG) > 99.7% @ 700 - 900nm @ 45° AOI

GDD:

S-POLARIZATION: 0 ± 20fs² @ 700 - 900nm P-POLARIZATION: 0 ± 20fs² @ 740 - 860nm

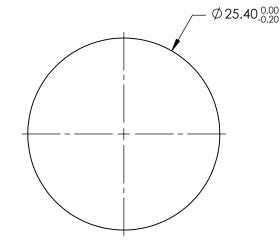
TOD:

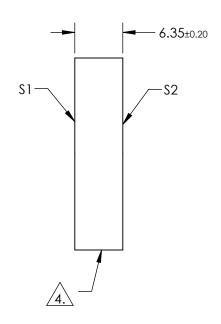
S-POLARIZATION: 10fs² @ 800nm P-POLARIZATION: 40fs² @ 800nm

S2: NONE

4. FINE GRIND SURFACE

5. RoHS: COMPLIANT





FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

	\$1	S2	
SHAPE PLANO		PLANO	
SURFACE QUALITY	10-5	COMMERCIAL POLISH	
SURFACE FLATNESS	λ/10	N/A	
CLEAR APERTURE Ø21.84		N/A	
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED	
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THIRD ANGLE PROJECTION	\bigcirc	T
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ALL DIMS IN	mm	D

Ec	lmu	nd	Op	tics®

700 - 900nm, 25.4mm DIA., ULTRAFAST
BROADBAND LASER MIRROR

mm	DWG NO	62766	SHEET 1 OF 1
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